## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**Applicants** 

:Kiyoshi AIDA et al.

Group Art Unit: 2837

Appl. No.

: 10/565,785

Examiner: C.M. RUSSELL

Filed

: January 25, 2006

Confirmation No.: 7530

For

: DUCT WALL STRUCTURE

## COMMENTS ON STATEMENT OF REASONS FOR ALLOWANCE

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, Mail Stop <u>Issue Fee</u>
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

In response to the Notice of Allowability, mailed by the U.S. Patent and Trademark Office on February 18, 2009, and to the Statement of Reasons for Allowance attached thereto, Applicants wish to clarify the record with respect to the basis for the patentability of claims in the present application. In this regard, while Applicants do not disagree with the Examiner's indication of allowability, Applicants submit that each of the claims in the present application recite a combination of features, and that the basis for patentability of each of these claims is based on the combination of features recited therein.

Should there be any questions, the Examiner is invited to contact the undersigned at the below-listed telephone number.

Respectfully Submitted, Kiyoshi AIDA et al.

William S. Boshnick

Reg. No. 44550

May 11, 2009 GREENBLUM & BERNSTEIN, P.L.C. 1950 Roland Clarke Place Reston, VA 20191 (703) 716-1191

Enoch E. Peavey Reg. No. 57,686